



Docket No.: 29137.096.00
(PATENT) *IFW*

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
KIM, Dong-seok *et al.*

Customer No.: 30827

Application No.: 10/550,591

Confirmation No.: 1374

Filed: September 23, 2005

Art Unit: 1711

For: TRANSPARENT, HIGHLY HEAT-
RESISTANT POLYIMIDE PRECURSOR AND
PHOTOSENSITIVE POLYIMIDE
COMPOSITION THEREOF

Examiner: Listvoyb, Gregory

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT WITHOUT TRAVERSE

Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed April 18, 2007, Applicants hereby provisionally elect claims 1-3 (Group I) drawn to polyimide precursor, for continued examination, without prejudice or disclaimer. Applicants retain the right to request rejoinder if and when the elected claims are allowed, pursuant to M.P.E.P. § 821.04.

If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. § 1.136, and any additional fees required under 37 C.F.R. § 1.136 for any necessary extension of time, or any other fees required to complete the filing of this response, may be charged to Deposit Account No. 50-0911. Please credit any overpayment to deposit Account No. 50-0911. A duplicate copy of this sheet is enclosed.

Dated: May 14, 2007

Respectfully submitted,

By

Mark R. Kresloff
Mark R. Kresloff

Registration No.: 42,766
McKenna Long & Aldridge LLP
1900 K Street, N.W.
Washington, D.C. 20006
Voice: 202-496-7500
Fax: 202-496-7756
Attorney for Applicants